

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Patent Application of:	)	
Shinji MAEKAWA et al.	)	Confirmation No.: 3488
Application No. 10/579,800	)	Examiner: Hoai V. Pham
Filed: May 19, 2006	)	Group Art Unit: 2892
For: ELECTRIC APPLIANCE	)	
SEMICONDUCTOR DEVICE, AND	)	
METHOD FOR MANUFACTURING THE	)	Date: August 21, 2008
SAME	)	

**RESPONSE TO REQUEST FOR RESTRICTION REQUIREMENT**

**Mail Stop: Amendment**  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In response to the Request for Restriction Response mailed July 24, 2008, Applicant responds as follows.

**REMARKS**

The Office Action of July 24, 2008 was received and carefully reviewed. Applicant hereby elects without traverse, Group I, Claims 1-18, drawn to a method for manufacturing a semiconductor device.

Consideration and allowance of the instant application are now respectfully requested.

Respectfully submitted,

/Jeffrey L. Costellia, Reg.#35,483/  
Jeffrey L. Costellia

NIXON PEABODY LLP  
401 9<sup>th</sup> Street N.W.  
Washington, D.C. 20004  
(202) 585-8000